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Title: System and Method for Measuring Optical Distance

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GOVERNMENT SUPPORT

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BACKGROUND OF THE INVENTION

Phase-based optical interferometric techniques are widely employed in optical distance measurements in which sub-wavelength distance sensitivity is required.

5 Optical distance is defined as the product of the refractive index and the length.

However, most such techniques are limited by an issue which is widely known in the field as 2π ambiguity or integer ambiguity which can be defined as the difficulty in telling the interference fringes of an axial scan apart from each other. An unmodified harmonic phase based low coherence interferometry method (HPI) can be used to

10 determine the differential optical distance, $(n_{\lambda_2} - n_{\lambda_1})L$, where L is the physical

distance, n_{λ_1} and n_{λ_2} are the refractive indices at the wavelengths λ_1 and λ_2

respectively, if the optical distance is increased gradually so that the differential phase measured by HPI can be tracked through its 2π wrap over. To determine $(n_{\lambda_2} - n_{\lambda_1})$ for

DNA in solution, for example, the DNA concentration is gradually increased in the

15 measuring cuvette. While such a measurement approach works well in a controlled environment, it can hardly be implemented in a situation where there is less

manipulability in the sample. For example, the method does not work on a fixed slab of material which we are constrained to keep whole.

The problem lies in the fact that unmodified HPI is unable to tell the interference fringes of an axial scan apart from each other, described herein as the 2π ambiguity

5 issue. It is a problem that plagues most phase-based optical interferometric techniques.

As a result, these techniques are unable to determine optical distance absolutely.

Therefore, most such techniques are used in applications, such as evaluating the texture of continuous surfaces or detecting time-dependent distance changes, in which phase unwrapping is possible through comparison of phases between adjacent points or over

10 small time increments.

SUMMARY OF THE INVENTION

The methods of the present invention are directed at an accurate phase-based technique for measuring arbitrarily long optical distances, preferably with sub-

15 nanometer precision. A preferred embodiment of the present invention employs an interferometer, for example, a Michelson interferometer, with harmonically related light sources, one continuous wave (CW) and a second source having low coherence (LC).

The low coherence source provides a broad spectral bandwidth, preferably a bandwidth of greater than 5 nm for a 1 micron (μ) wavelength, for example, the required bandwidth

20 can vary as a function of wavelength and application. By slightly adjusting the center wavelength of the low coherence source between scans of the target sample, the phase relationship between the heterodyne signals of the CW and low coherence light can be

used to measure the separation between reflecting interfaces with sub-nanometer precision. As this technique is completely free of 2π ambiguity, an issue that plagues most phase-based techniques, it can be used to measure arbitrarily long optical distances without loss of precision. An application of a preferred embodiment of the method of the present invention is the precision determination of the refractive index of a sample at a given wavelength of a sample with a known physical thickness. Another application of a preferred embodiment of the method of the present invention is the precision determination of a sample's physical thickness with a known refractive index. A further application of a preferred embodiment of the method of the present invention is the precision determination of the refractive index ratio at two given wavelengths.

In an alternate preferred embodiment, the low coherence light source provides a sufficiently broad bandwidth light, preferably greater than 5 nm, to provide simultaneously a first low coherence wavelength and a second low coherence wavelength with the respective center wavelengths separated from each other by more than approximately 2 nm. The frequency spectrums for the low coherence wavelengths do not significantly overlap. An additional detector and filters are disposed in the interferometer to transmit and detect the two low coherence wavelengths.

The preferred embodiment methods can be used to make precise optical distance measurements. From such measurements, optical properties of target objects can be accurately measured. By measuring the dispersion profile of the target, structural and/or chemical properties of the target can be evaluated. The dispersion profile maps out the refractive index differences at various wavelengths. In the biomedical context,

preferred embodiments of the present invention can be used to accurately determine the dispersion properties of biological tissues in a non-contact and non-invasive manner.

Such dispersion determination can be used on the cornea or aqueous humor of the eye.

The sensitivity achieved can be sufficient to detect glucose concentration dependent

5 optical changes. In a preferred embodiment of the present invention method, the blood glucose level can be determined through non-invasive measurements of the dispersion profile of either the aqueous, vitreous and/or aqueous and/or aqueous humor or the cornea of the eye. A preferred embodiment of the present invention can be applied as a measurement technique in semiconductor fabrication to measure small features formed
10 during the manufacturing of integrated circuits and/or optoelectronic components. As the preferred embodiment of the method is non-contact and non-destructive, it can be used to monitor the thickness of semiconductor structures or optical components as they are being fabricated.

15 BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is a schematic diagram of a preferred embodiment of the system to measure an optical distance in accordance with the present invention;

Figure 2 illustrates the low coherence heterodyne signals associated with a reflecting interface in accordance with a preferred embodiment wherein adjusting the
20 low coherence wavelength compresses or expands (depending on the direction of adjustment of the center wavelength of the low coherence source) the heterodyne signal around the interface;

Figure 3 illustrates heterodyne signals associated with two reflecting interfaces in a sample in accordance with a preferred embodiment wherein decreasing the low coherence wavelength compresses the heterodyne signal around the interfaces;

Figure 4 illustrates a scan of a sample with two interfaces in accordance with a preferred embodiment of the present invention (a) low coherence heterodyne signal, (b) trace wherein the magnified view shows the phase fringes, each fringe corresponds to an optical distance of λ_{CW} , (c) traces at two difference values of Δ , wherein the arrows indicate the phase crossing points, the vertical axis is in radians;

Figure 5 illustrates a method of determining correct estimates of $(n_{755nm}L)$ measured by choosing the values that minimizes the error between estimates based on S_{phase} and S_{fringe} in accordance with a preferred embodiment of the present invention;

Figures 6A and 6B are a flow chart illustrating a method to measure an optical distance in accordance with a preferred embodiment of the present invention;

Figure 7 is a schematic diagram of an alternate preferred embodiment of the system to measure an optical distance in accordance with the present invention;

Figures 8A and 8B are a flow chart illustrating an alternate method to measure an optical distance in accordance with a preferred embodiment of the present invention;

Figure 9 schematically illustrates a preferred embodiment of a fiber based system to measure the thickness of an optically transmissive material such as a glass slab, tissue sample or layer; and

Figure 10 illustrates a preferred embodiment of the present invention system used in a vitreous and/or aqueous humor glucose measurement system in accordance with the present invention.

The foregoing and other objects, features and advantages of the invention will be apparent from the following more particular description of preferred embodiments of the invention, as illustrated in the accompanying drawings in which like reference characters refer to the same parts throughout the different views. The drawings are not necessarily to scale, emphasis instead being placed upon illustrating the principles of the invention.

5 DETAILED DESCRIPTION OF THE INVENTION

The present invention is directed at phase crossing based systems and methods for measuring optical distances that overcome the integer or 2π ambiguity problem by introducing a dispersion imbalance in an interferometer. A preferred embodiment of the method is able to measure the relative height difference of two adjacent points on a
10 surface with precision. Further, the refractive index of a sample can be found to an accuracy that is limited only by the precision with which the physical thickness of the sample can be experimentally measured.

The substitution of one of the low coherence light sources with a continuous wave (CW) light source in the harmonic phase based interferometry (HPI), allows the
15 use of the associated CW heterodyne signal as a form of optical ruler by which the low coherence heterodyne signal can be measured. The low coherence light source provides

a spectral bandwidth, for example, greater than 5 nm for 1 micron wavelength. One of the benefits of using such a modified HPI is that the measured phase is now sensitive to the length scale nL instead of $(n_{\lambda_2} - n_{\lambda_1})L$, where n is the refractive index at the low coherence wavelength. The quantity n is more practically useful than the composite
5 $(n_{\lambda_2} - n_{\lambda_1})$. By adjusting the low coherence wavelength slightly, for example, by approximately 2 nm, the quantity nL can be found without 2π ambiguity and with sub-nanometer sensitivity. This method uses the CW heterodyne interference signal as a reference optical ruler by which the optical distance is measured.

Interferometric optical distance measuring systems employing readily available
10 low coherence light sources have achieved resolution on the order of tens of wavelengths. While this technique is relatively insensitive, it does not have to contend with the 2π ambiguity issue. A preferred embodiment includes a low coherence interferometry method that uses phase to measure arbitrarily long optical distances with sub-nanometer precision. This method uses a low coherence phase crossing technique
15 to determine the integer number of interference fringes, and additional phase information from the measurement to accurately obtain the fractional fringe. In addition, it provides depth resolution and can be used for tomographic profiling of stratified samples. As the method can measure long optical distances with precision, it can be used to determine refractive indices of a plurality of materials accurately. As this
20 is a phase-based method, the refractive index thus found is the phase refractive index and not the group refractive index.

Figure 1 illustrates a preferred embodiment of the system 10 of the present invention that includes a modified Michelson interferometer. The input light 12 is a two-color composite beam composed of 150-fs mode-locked light from a Ti:sapphire laser, for example, emitting at 775.0 nm and continuous wave (CW) 1550.0 nm light from, for example, a semiconductor laser. In the preferred embodiment the method evaluates optical distances in terms of the CW wavelength, (1550.0 nm exactly in this embodiment) and all optical distances are computed based on this basis. The composite beam is divided in two at the beamsplitter 14. One part signal is incident on the target sample 16, while the other is incident on a reference mirror 32 moving preferably at, for example, approximately 0.5 mm/s, which induces a Doppler shift on the reference beam 34. The Doppler shift can be induced by other means, such as, for example, through the use of an electro-optical modulator. The back-reflected beams are recombined at the beamsplitter 14, separated into their wavelength components by means of a dichroic mirror 18, and measured separately with photodetectors 20, 22. The resulting signals are digitized by an analog to digital converter (ADC) 24 such as, for example, a 16-bit 100 KHz A/D converter. A data processor such as a personal computer (PC) 26 is in communication with the ADC 24 to further process the data. The resulting heterodyne signals at their respective Doppler-shifted frequencies are bandpassed around their respective center heterodyne frequencies and Hilbert transformed to extract the corresponding phases of the heterodyne signals, Ψ_{CW} and Ψ_{LC} . The subscripts CW and LC denote the 1550.0 nm continuous wave and 775.0 nm low coherence wavelength components, respectively.

The center wavelength of low coherence light is then adjusted by approximately 1-2 nm and a second set of Ψ_{CW} and Ψ_{LC} values is measured. From these two sets of readings, the various interfaces in the target sample can be localized with sub-nanometer precision. The processing of data for localization is described hereinbelow.

5 Consider a sample which consists of a single interface at an unknown distance x_I from the beamsplitter 14. The distance from the beamsplitter 14 to the reference mirror 32, x , is a known quantity at each time point in the scan of the reference mirror.

A method to find an approximate value for x_I is by scanning x and monitoring the resulting heterodyne signal in the recombined low coherence light beam. When x is
10 approximately equal to x_I , a peak in the heterodyne signal amplitude is expected. The precision of such a method is limited by the coherence length, l_c , of the light source and the signal-to-noise quality of the heterodyne signal. Under realistic experimental conditions, the error in x_I determined thus, is unlikely to be better than a fifth of the coherence length.

15 Given that the coherence length of a typical low coherence source is approximately 10 μm nominally, this means that the error in such a means of length determination is limited to about 2 μm .

In considering the phase of the heterodyne signal, the varying component of the heterodyne signal detected can be expressed as:

$$20 \quad \begin{aligned} I_{\text{heterodyne}} &= E_{\text{ref}} e^{i(2kx - \omega t)} E_{\text{sig}} e^{-i(2kx_I - \omega t)} + c.c. \\ &= 2E_{\text{ref}} E_{\text{sig}} \cos(2k(x - x_I)) \end{aligned} \quad (1)$$

where E_{ref} and E_{sig} are the electric field amplitude of the reference and signal electric field amplitude, respectively, k is the optical wavenumber, ω is the optical frequency. The factor of 2 in the exponents is due to the fact that light travels twice the path going to the mirror/sample and back to the beamsplitter.

- 5 Note that when x matches x_l exactly, the heterodyne signal is expected to peak. The two returning beams are in constructive interference. This property is therefore used to localize the interface. x_l is found by finding the value of x for which the two beams are in constructive interference. Since phase can be measured accurately, such an approach gives a length sensitivity of about 5 nm. Unfortunately, this method is
- 10 calculation intensive because there are multiple values of x for which the heterodyne signal peaks; specifically, the heterodyne signal peaks at:

$$x = x_l + a \frac{\lambda}{2}, \quad (2)$$

where a is an integer and λ is the optical wavelength. This is a manifestation of the 2π ambiguity issue.

- 15 The preferred embodiment includes a method to distinguish the correct peak. Note that when $x = x_l$ exactly, the heterodyne signal peaks regardless of the optical wavelength. On the other hand, the subsequent peaks are wavelength dependent, as illustrated in Figure 2. Figure 2 illustrates the low coherence heterodyne signals associated with the reflecting interface 52 in the sample. Therefore, by adjusting the
- 20 low coherence wavelength, the heterodyne signal is compressed around the interface and the correct peak associated with the situation where $x - x_l$ exactly can be

distinguished. It should be noted that the heterodyne signal may be compressed or expanded around the interface depending upon the direction of adjustment. An intuitive way of visualizing the localization is to picture the heterodyne signal squeezing in or expanding away from the fringe where $x = x_1$ exactly.

5 The CW light source is needed in such a localization method for two reasons. First, it is very difficult in practice to know the value absolutely and accurately in an interferometer. The CW component of the interferometer permits highly accurate measurements of x to be made as the reference mirror is scanned. In a specific preferred embodiment, to determine the distance between two interfaces in the sample, a count of
10 the number of CW interference fringes that occurred between where x_1 is equal to the distance to the first interface as shown in Figure 1 and where x_2 ($x_2 = x_1 + nL$ wherein n is the refractive index of the sample) is equal to the distance to the second interface is made. Figure 3 illustrates the heterodyne signals associated with two reflecting
15 interfaces in a sample. Adjusting the low coherence wavelength compresses 82, 84 the heterodyne signal 78, 80 around the interfaces.

 Second, the prior described method for localization of the interface may partly fail if there is a phase shift associated with the reflection process. For example, if the surface is metallic, the phase shift is non-trivial and the phase of the heterodyne signal takes on some other value when $x = x_1$ exactly. While the prior method allows the
20 correct interference fringe to be identified where $x = x_1$, however sub-wavelength sensitivity may be compromised. The presence of the CW heterodyne signal allows the

difference phase via the HPI method to be found. The knowledge of this value, allows the localization of the interface with a high level of sensitivity.

The principle of the HPI method can be illustrated through the exemplary embodiment of a sample of thickness, L , and refractive index, n_{775nm} , at a wavelength of 775 nm. The two interfaces of the sample are at optical distances x_1 and x_2 (where $x_2 = x_1 + n_{775nm}L$) from the beamsplitter, respectively. Note that the method only works if the optical distance separation is greater than the coherence length, for example, typically between 1 micron and a 100 microns of the low coherence light source. Otherwise, the heterodyne phase signals associated with the interfaces merge together and result in inaccurate interface localization. For clarity of explanation, the incorporation of the phase shifts associated with reflection are deferred until later.

Figure 4 is a scan illustrating the mathematical description. The scan is of a sample with two interfaces. The signal 100 is a low coherence heterodyne signal. The trace 102 is $\psi_{CW}(x)$. The magnified view 104 shows the phase fringes. Each fringe corresponds to an optical distance of λ_{CW} . The lower traces of $\psi_D(x)$ are at two different values of Δ . The arrows 106, 110 indicate the phase crossing points. The vertical axis is in radians. As the reference mirror is scanned, the phase of the low coherence heterodyne signal is given by:

$$\begin{aligned} & \psi_{LC}(x) \\ &= \text{mod}_{2\pi} \left(\arg \left(R_{LC,1} e^{i2k_{LC}(x-x_1)} e^{-(2a(x-x_1))^2} + R_{LC,2} e^{i2k_{LC}(x-x_2)} e^{-(2a(x-x_2))^2} \right) \right) \\ &\approx h_c(x-x_1) \text{mod}_{2\pi} (2k_{LC}(x-x_1)) + h_c(x-x_2) \text{mod}_{2\pi} (2k_{LC}(x-x_2)), \end{aligned}$$

(3)

with R_{LCj} the reflectivity of the interface j at the low coherence wavelength, k the optical wavenumber, $a = 4 \ln(2)/l_c$, l_c the coherence length, x the distance of the reference mirror from the beamsplitter, and $h_c(x)$ a piecewise continuous function with

5 value of 1 for $|x| < 2l_c$ and 0 otherwise. The factors of 2 in the exponents are due to the effective doubling of optical paths in the back reflection geometry. Equation (3) reflects the fact that phase cannot be measured far beyond the coherence envelopes, due to noise. Although the coherence envelopes modeled are gaussian in profile, the same phase treatment is valid for profiles of any slowly varying envelope.

10 The phase of the CW heterodyne signal is given by:

$$\begin{aligned} \psi_{cw}(x) &= \text{mod}_{2\pi} \left(\arg \left(R_{cw,1} e^{i2k_{cw}(x-x_1)} + R_{cw,2} e^{i2k_{cw}(x-(x_1+n_{1550nm}L))} \right) \right) \\ &= \text{mod}_{2\pi} \left(\arg \left(\bar{R} e^{i2k_{cw}(x-\bar{x})} \right) \right) = \text{mod}_{2\pi} (2k_{cw}(x-\bar{x})), \end{aligned} \quad (4)$$

with R_{CWj} the reflectivity of the interface j at the CW wavelength, n_{1550nm} the sample's refractive index, \bar{R} and \bar{x} the effective average reflectivity and distance from the beamsplitter, respectively. If the center wavelengths of the two light sources

15 are chosen such that

$$k_{LC} = 2k_{cw} + \Delta, \quad (5)$$

where Δ is a small intentionally added shift, then a difference phase, ψ_D , of the form is obtained:

$$\begin{aligned} \psi_D(x) &= \psi_{LC}(x) - 2\psi_{cw}(x) \\ &= h_c(x-x_1) \text{mod}_{2\pi} (4k_{cw}(\bar{x}-x_1) + 2\Delta(x-x_1)) + h_c(x-x_2) \text{mod}_{2\pi} (4k_{cw}(\bar{x}-x_2) + 2\Delta(x-x_2)). \end{aligned} \quad (6)$$

20

The above quantity provides both the approximate number of fringes in the interval $(x_2 - x_1)$ and the fractional fringe, which provides sub-wavelength precision.

As the parameter Δ is varied by a small amount (corresponding to a wavelength shift of approximately 1-2 nm), the slope of $\psi_D(x)$ pivots around the points where

5 $x = x_1$ and $x = x_2$. In other words, the phase scans at different values of Δ crosses at those points. The optical distance from x_1 to x_2 can be found by counting the fringes that $\psi_{cw}(x)$ goes through between the two phase crossing points. Twice the quantity thus found is denoted by S_{fringe} , which is not an integer value, and corresponds to the number of fringes at the low coherence wavelength. In the event where multiple phase
10 crossing points occur for a single interface, the point that corresponds to the position of the interface can be found by making multiple scans at additional values of Δ . The position of the interface is the only location where $\psi_D(x)$ will cross for all Δ values.

The phase shift information is used to further localize the interface separation.

Specifically, the difference between the phase shifts at $x = x_1$ and $x = x_2$ is:

$$15 \quad S_{phase} = \frac{\text{mod}_{2\pi}(\psi_D(x = x_1) - \psi_D(x = x_2))}{2\pi} = \frac{\text{mod}_{2\pi}(4k_{cw}(x_2 - x_1))}{2\pi}. \quad (7)$$

This measures the fractional fringe with great sensitivity.

The absolute optical separation $(x_2 - x_1)$ can be determined with precision from

S_{fringe} and S_{phase} through the following equation:

$$20 \quad (x_2 - x_1)_{measured} = (n_{775nm}L)_{measured} = \frac{\lambda_{cw}}{4} \left(\left[\text{int}(S_{fringe}) + U\left(\Delta S - \frac{1}{2}\right) - U\left(-\Delta S - \frac{1}{2}\right) \right] + S_{phase} \right) \quad (8)$$

where $\Delta S = \text{res}(S_{\text{fringe}}) - S_{\text{phase}}$ and $U(\)$ is a unit step function. Here, $\text{int}(\)$ and $\text{res}(\)$ denote the integer and fractional parts of the argument respectively. The first term localizes the optical distance to the correct integer number of fringes by minimizing the error between S_{phase} and the fractional part of S_{fringe} . The error of an optical separation determination is limited only by the measurement error of S_{phase} . In an experiment such error translates to an error in $(n_{775\text{nm}}L)_{\text{measured}}$ of approximately 0.5 nm. The measurement error of S_{fringe} needs only be smaller than half a fringe so that the correct interference fringe can be established; having satisfied this criterion, it does not enter into the error of $(n_{775\text{nm}}L)_{\text{measured}}$. The maximum measurable optical distance simply depends on the ability of the system to accurately count fringes between two crossing points and the frequency stability of the light sources.

The above equation is a condensed expression of the method for finding the correct fringe and the fractional fringe. The operation can be illustrated through the following example and Figure 5 which shows the determination of the correct estimate of $(n_{775\text{nm}}L)_{\text{measured}}$ by choosing the value that minimizes the error between estimates based on S_{phase} and S_{fringe} . Assume that S_{fringe} and S_{phase} are 26.7 and 0.111. From the measurement of S_{phase} , the optical distance of the value is:

$$(n_{775\text{nm}}L)_{\text{measured}} = \frac{\lambda_{\text{cw}}}{4}(a + 0.111), \quad (9)$$

where a is an integer. Given the value of S_{fringe} , the possible values of

$(n_{775\text{nm}}L)_{\text{measured}}$ can be limited to the following 3 values: $\frac{\lambda_{\text{cw}}}{4}(25.111)$, $\frac{\lambda_{\text{cw}}}{4}(26.111)$

and $\frac{\lambda_{cw}}{4}(27.111)$. Given that the value of $\frac{\lambda_{cw}}{4}(27.111)$ is closest to $\frac{\lambda_{cw}}{4}(S_{fringe})$, it is the correct estimate of $(n_{775nm}L)_{measured}$.

In preferred embodiments for interferometry experiments based on harmonically related light sources, the appropriately chosen pair of light sources and the method of extracting difference phase allows the minimization and preferably the elimination of the effect of jitter in the interferometer, which would otherwise make high precision optical distance measurement impossible. The elimination of jitter also allows the comparison of scans performed at different times.

To demonstrate the capability of a preferred embodiment of the method, the system is used to probe the optical distance between the top and bottom surface of a fused quartz cover slip having a physical thickness, $L = 237 \pm 3 \mu\text{m}$. In this embodiment there is a π phase shift associated with reflection from the first interface, that marks a positive refractive index transition. Hence, there is a $e^{-i\pi}$ term associated with the factors $R_{LC,1}$ and $R_{cw,1}$ in equations (1) and (2). This results in a correction factor of half on S_{fringe} and S_{phase} . Figure 4 shows the result of typical scans at the LC wavelengths of 773.0 nm and 777.0 nm. The results of four scans are summarized in Table 1 which represents measurements of $(n_{755nm}L)$ on a piece of quartz cover slip. The repeatability of the experimental data indicates that the light source are sufficiently stable in frequency.

	$\frac{\lambda_{cw}}{4} S_{fringe} (\mu m)$	$\frac{\lambda_{cw}}{4} S_{phase} (\mu m)$	$(n_{775nm} L)_{measured} (\mu m)$
Set 1	350.86 ± 0.17	0.3496 ± 0.0004	351.0371 ± 0.0004
Set 2	351.08 ± 0.17	0.3497 ± 0.0004	351.0372 ± 0.0004
Set 3	351.15 ± 0.16	0.3502 ± 0.0004	351.0377 ± 0.0004
Set 4	351.04 ± 0.18	0.3498 ± 0.0004	351.0373 ± 0.0004
Average			351.0373 ± 0.0004

Table 1

The experimental data yields an optical absolute distance measurement with sub-nanometer precision. The optical distance found is associated with the low coherence light source. The CW heterodyne signal serves as an optical ruler. If L of the quartz cover slip is known precisely, n_{775nm} for quartz at the wavelength 775.0 nm can be found to a very high degree of accuracy from $(n_{775nm} L)_{measured}$.

Alternatively, without knowing the exact value of L , the refractive index ratio at two different wavelengths can be determined by measuring the corresponding optical distances using low coherence light at these wavelengths and CW light at their respective harmonics. Using a range of low coherence wavelengths, the dispersion profile of a material can be determined accurately. The dispersion profile maps out the refractive index differences at various wavelengths. The experimental results in accordance with a preferred embodiment predict that a precision of approximately seven significant figures can be achieved with an approximately 1 mm thick sample.

In another preferred embodiment the light sources of the system are changed to a low coherence superluminescent diode (SLD) emitting at 1550.0 nm and a CW Ti:Sapphire laser emitting at 775.0 nm. By adjusting the operating current through the SLD the center wavelength is changed by about 2 nm; this is adequate to achieve phase

crossing. Using this preferred embodiment of the present invention system, the optical distance can be measured at 1550.0 nm. Taking the ratio of the result of this measurement with the previous measurement, the ratio of the refractive indices n_{775nm} / n_{1550nm} for quartz can be determined. It should be noted that the index ratios found are for harmonically related wavelengths due to the sources used in the preferred embodiments. Refraction index ratios for other wavelengths can be measured with other appropriate choices of light sources. For comparison, the corresponding data for glass and acrylic plastic are tabulated in Table 2 as measurements of n_{775nm} / n_{1550nm} for different materials.

	n_{775nm} / n_{1550nm}
Quartz	1.002742 ± 0.000003
Glass (German borosilicate)	1.008755 ± 0.000005
Acrylic plastic	1.061448 ± 0.000005

Table 2

Note that some of the equations used when the low coherence wavelength is half that of the CW wavelength are slightly different from the equations previously presented herein. For example:

$$\begin{aligned}
 & \psi_{LC}(x) \\
 &= \text{mod}_{2\pi} \left(\arg \left(R_{LC,1} e^{i2k_{LC}(x-x_1)} e^{-\left(\frac{2}{l_c}(x-x_1)\right)^2} + R_{LC,2} e^{i2k_{LC}(x-x_2)} e^{-\left(\frac{2}{l_c}(x-x_2)\right)^2} \right) \right) \\
 &\approx h_c(x-x_1) \text{mod}_{2\pi}(2k_{LC}(x-x_1)) + h_c(x-x_2) \text{mod}_{2\pi}(2k_{LC}(x-x_2)),
 \end{aligned}
 \tag{10}$$

$$\begin{aligned}\psi_{cw}(x) &= \text{mod}_{2\pi} \left(\arg \left(R_{cw,1} e^{i2k_{cw}(x-x_1)} + R_{cw,2} e^{i2k_{cw}(x-(x_1+n_{1550nm}L))} \right) \right) \\ &= \text{mod}_{2\pi} \left(\arg \left(\bar{R} e^{i2k_{cw}(x-\bar{x})} \right) \right) = \text{mod}_{2\pi} (2k_{cw}(x-\bar{x})),\end{aligned}\quad (11)$$

$$2k_{LC} = k_{cw} + \Delta, \quad (12)$$

5

$$\begin{aligned}\psi_D(x) &= 2\psi_{LC}(x) - \psi_{cw}(x) \\ &= h_c(x-x_1) \text{mod}_{2\pi} (4k_{LC}(\bar{x}-x_1) + 2\Delta(x-x_1)) + h_c(x-x_2) \text{mod}_{2\pi} (4k_{LC}(\bar{x}-x_2) + 2\Delta(x-x_2))\end{aligned}\quad (13)$$

$$S_{phase} = \frac{\text{mod}_{2\pi}(\psi_D(x=x_1) - \psi_D(x=x_2))}{2\pi} = \frac{\text{mod}_{2\pi}(4k_{LC}(x_2-x_1))}{2\pi}. \quad (14)$$

$$10 \quad (x_2 - x_1)_{measured} = (n_{775nm}L)_{measured} = \frac{\lambda_{LC}}{4} \left(\left[\text{int}(S_{fringe}) + U\left(\Delta S - \frac{1}{2}\right) - U\left(-\Delta S - \frac{1}{2}\right) \right] + S_{phase} \right) \quad (15)$$

Preferred embodiments of the methods for overcoming 2π ambiguity is of significant use in applications such as high precision depth ranging and high precision refractive index determination of thin film solid state materials.

15 The use of the preferred methods can be illustrated through consideration of a slab of glass. There exist systems that can measure the distance from the systems to the averaged center of the glass slab very accurately. There are also systems that can measure the roughness of the glass surface very accurately. A preferred embodiment of the present invention system measures with nanometer sensitivity the thickness of the
20 glass slab end-face.

The steps in the implementation of a preferred embodiment of the method to determine the optical distance are illustrated in the flow chart 124 in Figures 6A and 6B.

The method 124 includes the use of two harmonically related light sources in a Michelson interferometer, one of which is a CW source while the other is a low coherence source. The sample for which the optical distance needs to be measured between its interfaces is used as the end reflectors of the signal interferometer arm per
5 step 126. The reference mirror in the reference interferometer arm is scanned per step 128. The method includes the step 130 in which the reflections from the signal and reference arms are combined and separated by wavelength. Further, per step 132 the heterodyne oscillations in the intensities of the combined light are detected. The phases of the heterodyne signals for both wavelengths are then found via, for example, a
10 Hilbert transform or any alternate phase extraction method per step 134. A difference phase given by subtracting twice the phase of the longer wavelength from the shorter is evaluated for the whole scan per step 136. The scan is repeated with the wavelength of the light being slightly detuned per step 137. Steps 130-136 are then repeated.

The two difference phases found from the two scans are then superposed on each
15 other on a graph with the x-axis representing the displacement of the reference mirror per step 138. It should be noted that the extraction of difference phases can also be done with the appropriate light sources or chromatic filters or software/hardware signal processing on a single scan.

The next step in method 124 includes determining the phase crossing points on a
20 graph to mark the locations of the sample interfaces per step 140. By counting the number of times the heterodyne signal associated with the CW light wraps over by 2π between the two crossing points, the optical separation between the interfaces is

determined per step 142 with accuracy to about a fraction of a wavelength, for example, of approximately 0.2. By measuring the difference phase at the crossing points, further localization and/or refining of the separation to a very small fraction of a wavelength, for example, approximately 0.001.

5 In another preferred embodiment as illustrated in Figure 7 which is a schematic diagram of the system to measure optical distance, the low coherence light source may be sufficiently broad in bandwidth, for example, more than 4 nm. On the detection end, a third detector 174 is added to the two detectors 166, 176. This results in the low coherence light signal 168 being further split into two. Prior to reaching the detectors,
10 the two light beams are passed through different filters 170, 172. The filters transmit different parts of the spectrum. One passes the longer wavelength spectra component, while the second, the shorter wavelength spectral component. Preferably the two transmitted beams are separated in their spectrum by more than 2 nm.

The light beams are then incident on the detectors and their heterodyne signals
15 are processed in the fashion discussed with respect to Figure 1. The advantage of this method in accordance with alternate preferred embodiment is that the method eliminates the repetition of the process with an adjusted low coherence wavelength. The two signals are acquired in the same scan.

Figures 8A and 8B illustrate a flowchart 184 of an alternate method to measure
20 an optical distance in accordance with a preferred embodiment of the present invention. The method 184 includes the use of two harmonically related light sources in an interferometer one of which is a CW source while the other is a low coherence source.

The sample for which the optical distance needs to be measured is used as the end reflectors of the signal interferometer arm per step 186. The reference mirror in the reference interferometer arm is scanned per step 188. The method further includes the step 190 of combining the reflections from the signal and reference arms and separating them by wavelength. The low coherence wavelength is further separated using filters per step 192. The method 184 includes the step 194 of detecting the heterodyne oscillations with at least three detectors. The next step 196 includes detecting the heterodyne oscillations in the intensities of the combined light. The phases of the heterodyne signals for both wavelengths are then found via, for example, a Hilbert transform or any alternate phase extraction method per step 198. A difference phase for each low coherence signal with the CW signal is then evaluated per step 200.

The two difference phases are then superposed on each other on a graph with the x-axis representing the displacement of the reference mirror per step 202. The remaining steps 204, 206, 208 are similar to steps 140, 142, 144 as discussed with respect to Figure 6B.

The preferred embodiment of the method can be used to absolutely measure arbitrarily long optical distances with sub-nanometer precision. The preferred embodiment of the system can be free space based or fiber based. Figure 9 illustrates a preferred embodiment of a fiber based system to measure an optical distance.

The input light 256 includes approximately harmonically related low coherence light having a wavelength λ_1 and a CW light beam having a wavelength λ_2 which travel in fiber 251. The composite beam is divided in two, one part of the signal is incident on

the target lens 254 and sample 256 and travels in fiber 253 while the other is incident on the reference mirror 266 via a lens 268 and travels in fiber 251. The movement of the reference mirror introduces a Doppler shift on the reflected beam. The reflected beams are recombined and then separated into their component wavelength components by means of the dichroic mirror 258. These wavelength components are measured separately with photodetectors 260, 262. The resulting heterodyne signals at their respective Doppler-shifted frequencies are bandpassed around their respective center heterodyne frequencies and Hilbert transformed to extract the corresponding phases of the heterodyne signals, ψ_{CW} and ψ_{LC} .

10 The preferred embodiment methods can be used to make precise optical distance measurements. From such measurements, optical properties of target objects can be accurately measured. By measuring the dispersion profile of the target, structural and/or chemical properties of the target can be evaluated. In the biomedical context, preferred embodiments of the present invention can be used to accurately determine the

15 dispersion property of biological tissues in a non-contact and non-invasive manner. Such dispersion determination can be used on the cornea or aqueous humor of the eye. The sensitivity achieved can be sufficient to detect glucose concentration dependent optical changes. In a preferred embodiment of the present invention method, the blood glucose level can be determined through non-invasive measurements of the dispersion

20 profile of either the aqueous, vitreous humor or the cornea of the eye.

As discussed hereinbefore, phase based interferometry methods are able to measure optical distances very sensitively. However, they are typically limited in their

applications by a problem that is widely known in the field as the 2π ambiguity problem. The crux of this problem is that it is impossible to differentiate a length of 10.1 wavelengths from the length of 11.1 wavelengths. The preferred embodiments of the present invention overcome this limitation and allow absolute optical distance

5 measurements with sub-nanometer accuracy.

There are numerous phase based methods that measure changes in optical distances with a sensitivity of approximately the nm range. As long as the change is small and gradual, the change can be continuously tracked. There are low coherence methods that measure absolute optical distance by tracking the delay in arrival at the

10 detector of light reflected from different interfaces of the reflector sensitivity in approximately microns. As discussed hereinbefore, the simultaneous use of a CW and a low coherence light sources in an interferometer provides for the methods to measure optical distance. The heterodyne phases of the signals associated with the two wavelengths are intrinsically related. By processing the phase per the preferred

15 embodiments, motional noise is minimized and preferably eliminated from our measurements.

An application of a preferred embodiment is the glucose level determination using the measurement of the refractive index of the vitreous and/or aqueous humor of the eye. The sensitivity of this technique affords the ability to measure chemical

20 concentrations with a sensitivity that is clinically relevant. One of the more obvious applications of the method of a preferred embodiment is the determination of blood

glucose level through measurements performed on the eye. The glucose level of the fluid in the eye mirrors that of the blood with clinical insignificant time delay.

The method of a preferred embodiment measures the optical path lengths of the vitreous and/or aqueous humor layer in the eye at least two separate sets of wavelengths as illustrated in Figure 10. The method measures the product of the refractive index at the low coherence wavelength and the physical separation between two interfaces. By changing the wavelength of the low coherence light source (and appropriately changing the CW wavelength to match), the refractive index difference at different wavelengths is measured. For example, one set of experiment is performed with a tunable 500 nm low coherence light source and a one micron CW light source to extract $n_{500\text{nm}}L$ where L is the physical thickness of the vitreous and/or aqueous humor at the point of measurement. Another set of experiments is performed with a tunable 1000 nm low coherence light source and a 1800 nm CW light source to extract $n_{900\text{nm}}L$. By taking the ratio of these two measurements, the refractive index ratio, $n_{500\text{nm}}/n_{900\text{nm}}$, of the vitreous and/or aqueous humor is extracted. With the existing sensitivity, for example, 0.5 nm optical path sensitivity, a preferred embodiment of the system, the ratio $n_{500\text{nm}}/n_{900\text{nm}}$ with 10^{-8} sensitivity can be measured for a material of thickness equal to that of the human vitreous and/or aqueous humor. This provides the sensitivity to changes in the glucose level of about 0.25 mg/dl. Given that the typical blood glucose level is about 100 mg/dl, a preferred embodiment of the present invention is well suited for blood glucose assessment. The choice of optical wavelengths is flexible, the wavelength used hereinabove is simply for illustration purpose. For maximal sensitivity, the wavelength

separation is preferably as large as possible. Preferred embodiments include a separation of greater than 500 nm.

In the event that such a refractive index ratio is insufficient for absolute blood glucose level determination due to the presence of other chemicals that is changing in the vitreous and/or aqueous humor, a more complete range of optical path length measurement can be made at a range of other wavelengths. This set of more complete measurement allows the determination of glucose level and other chemical concentrations by fitting the measurements to known dispersion profiles of glucose and other chemicals.

10 A preferred embodiment of the present invention can be applied as a measurement technique in semiconductor fabrication. As the preferred embodiment of the method is non-contact and non-destructive, it can be used to monitor the thickness of semiconductor structures as they are being fabricated. In addition, the composition of the semiconductor structures can be assessed in much the same manner as that discussed
15 with respect to the characterization of the vitreous and/or aqueous humor measurements.

The claims should not be read as limited to the described order or elements unless stated to that effect. Therefore, all embodiments that come within the scope and spirit of the following claims and equivalents thereto are claimed as the invention.